

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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E. Usillis
7-24-01

In re the Application of

Martin E. LEE

Application No.: Rule 53(b) Divisional of 09/437,608 filed November 10, 1999

Filed: June 15, 2001

Docket No.: 102305.05

For: GUIDELESS STAGE WITH ISOLATED REACTION STAGE

PRELIMINARY AMENDMENT

Director of the U.S. Patent and Trademark Office
Washington, D.C. 20231

Sir:

Prior to initial examination on the merits, please amend the above-identified application as follows:

IN THE CLAIMS:

Please cancel claims 1-33 without prejudice to or disclaimer of the subject matter contained therein.

Please add the following claims 34-157:

--34. (new) A method of making a microlithography system that forms an image onto an object, comprising the steps of:

providing an irradiation apparatus that irradiates the object with radiation to form the image on the object;

providing a movable stage associated with the irradiation apparatus;

providing a first support structure;

B1

Sub.
C1